



Advanced packaging technology for Al and power semiconductors

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Abstract:

Packaging materials and processes with basic science has been intensively focused by many researchers and engineers in the world. These factors are the keys for us to explore new technology both for AI semiconductors and for WBG semiconductors. The superior functions of these semiconductors can be retrieved by basic science supporting device structures, especially materials combination and bonded interfaces. One of the examples will be shown as the nano voids issue for substrates. The weakness of built up substrates often causes serious failure incident in the market for many years. The most serious failure occurs at the microvias, which is sometimes called as "weak micro-via". Macroscopic observation of via bottom have been carried out by SEM and TEM by researchers. Nevertheless, root cause has not been yet understood until recently since nano voids are really in single nano size and no effective analytical method has been applied. Our group has carried out nano analysis by high resolution TEM and atom probe tomography with XPS on the nano voids and then, finally discovered the presence of substantial residues in the electroless Cu layer in via bottom of substrates. Followed by this finding, the removal of the residues can suppress the nano voids formation at via bottom. This modification in electroless Cu plating can improve the reliability of substrates. Thus, basic science providing new information on hetero-interfaces in semiconductors can open the effective ways to the reliable and excellent functions for advanced edge AI / WBG power semiconductors.

Speaker's Biography:

He received the degree of Dr. Engineer from Tohoku University in 1982. He became a research assistant of ISIR (Institute of Scientific and Industrial Research), Osaka University in 1982, an associate professor of National Defense Academy in 1986, and a professor of ISIR of Osaka University in 1996. He was the director of Nanotechnology Center of ISIR in 2007-2009, the director of ISIR in 2018-2020. He is currently Specially Appointed Professor and Professor Emeritus of Osaka University, Executive Advisor of Daicel Corp., Managing Director of Izumi



Science. He has worked on lead-free soldering, conductive adhesive, power electronics packaging and printed electronics. He published about 450 journal papers, 160 reviews and many books on packaging technology such as "Wide Bandgap Power Semiconductor Packaging". He is currently in charge of IEC SC47D Semiconductor Packaging Japan Committee/JEITA, of Advanced Semiconductor Task Force/JEITA, and of Standardization of Thermal Property Evaluation of WBG Power Devices/JFCA.